

# Konstantin Barkov

## List of Publications by Year in descending order

Source: <https://exaly.com/author-pdf/1576302/publications.pdf>

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12

papers

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citations

2682572

2

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2053705

5

g-index

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#	ARTICLE	IF	CITATIONS
1	Phase composition of the buried silicon interlayers in the amorphous multilayer nanostructures [(Co</scp>Fe</scp><sub>45</sub><scp>Zr</scp><sub>10</sub>) / <i>a</i>-Si</scp>: <sc>H</sc> and [(Co</scp>Fe</scp><sub>45</sub><scp>Zr</scp><sub>10</sub>) <sub>35</sub>(<sc>Al</sc><sub>2</sub><sc>O</sc><sub>3</sub>). Surface and Interface Analysis, 2018, 50, 1265-1270.	1.8	12
2	Electronic structure and phase composition of dielectric interlayers in multilayer amorphous nanostructure [(CoFeB)60C40/SiO<sub>2</sub>]200. Physics of the Solid State, 2017, 59, 168-173.	0.6	5
3	Electronic structure and phase composition of silicon oxide in the metal-containing composite layers of a [(Co<sub>40</sub>Fe<sub>40</sub>B<sub>20</sub>)34(SiO<sub>2</sub>)66/C]46 multilayer amorphous nanostructure with carbon interlayers. Inorganic Materials, 2017, 53, 930-936.	0.8	3
4	A study of multilayer nanostructures [(Co<sub>45</sub>Fe<sub>45</sub>Zr<sub>10</sub>) <sub>35</sub>(<sub>2</sub>O<sub>3</sub>)<sub>65</sub> / <i>a</i>-Si:H and [(Co<sub>45</sub>Fe<sub>45</sub>Zr<sub>10</sub>) <sub>35</sub>(<sub>2</sub>O<sub>3</sub>)<sub>65</sub> / <i>a</i>-Si] by means of XRD, XRR, IR spectroscopy, and USXES. EPJ Applied Physics, 2019, 87, 21301.	0.7	3
5	Phase Formation and Electronic Structure Peculiarities in the Al<sub>1-x</sub>Si<sub>x</sub> Film Composites under the Conditions of Magnetron and Ion-Beam Sputtering. Physics of the Solid State, 2018, 60, 1021-1028.	0.6	1
6	On the Phase Composition, Morphology, and Optical and Electronic Characteristics of AlN Nanofilms Grown on Misoriented GaAs(100) Substrates. Semiconductors, 2019, 53, 1550-1557.	0.5	1
7	Effect of GaAs(100) substrate misorientation on structural, electronic, and optical properties of AlN nano-sized films obtained by reactive plasma-ion deposition. Physica B: Condensed Matter, 2019, 563, 62-71.	2.7	1
8	Effect of Al<sub>3</sub>Si film thickness on the properties of Al<sub>3</sub>Si-Al<sub>2</sub>O<sub>5</sub> composites. Journal of Alloys and Compounds, 2019, 790, 130003.	1.0	1
9	Structural Rearrangement of a-SiO<sub>x</sub>:H Films with Pulse Photon Annealing. Kondensirovannye Sredy Mezhhafaznye Granitsy, 2020, 22, 489-495.	0.3	1
10	Effects of "simplest" post-treatment techniques on the composition of porous silicon surface. IOP Conference Series: Materials Science and Engineering, 2020, 889, 012023.	0.6	0
11	Effect of annealing temperature on the structure and properties of nanocrystalline Al<sub>2</sub>O<sub>3</sub> films. Journal of Alloys and Compounds, 2019, 790, 130002.	1.0	1
12	Effect of annealing temperature on the structure and properties of nanocrystalline Al<sub>2</sub>O<sub>3</sub> films. Journal of Alloys and Compounds, 2019, 790, 130002.	1.0	1